

ATTY DKT. NO.: AMAT/5620.C1/DSM/LOW K/JW
U.S. SERIAL NO.: UNKNOWN
FILED: HEREWITH
APPLICANT: APPLIED MATERIALS, INC.
TITLE: A METHOD OF ELIMINATING PHOTORESIST POISONING IN DAMASCENE
APPLICATIONS
INVENTOR: XU, ET AL.
EXPRESS MAIL LABEL: EV335471079US

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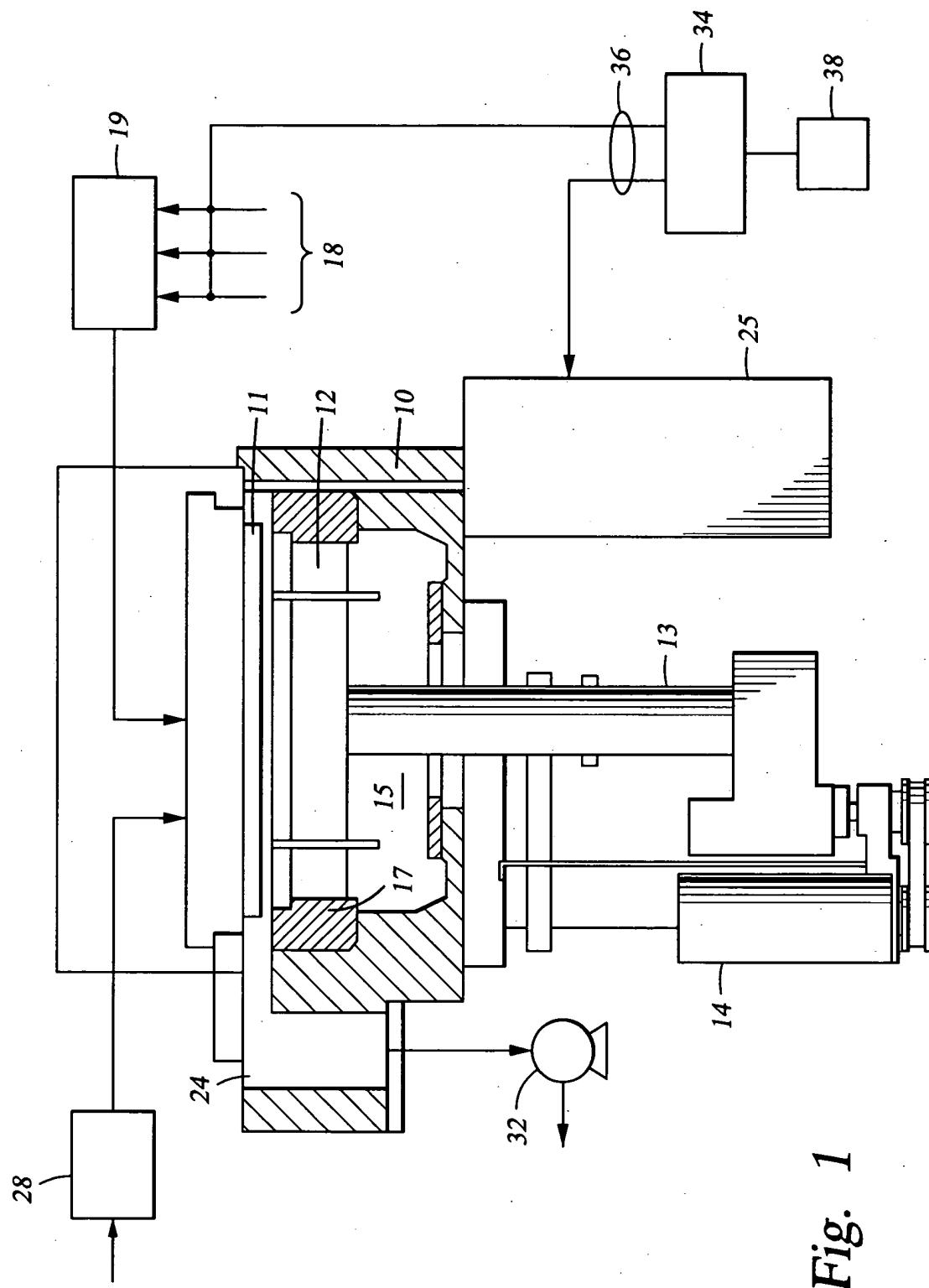


Fig. 1

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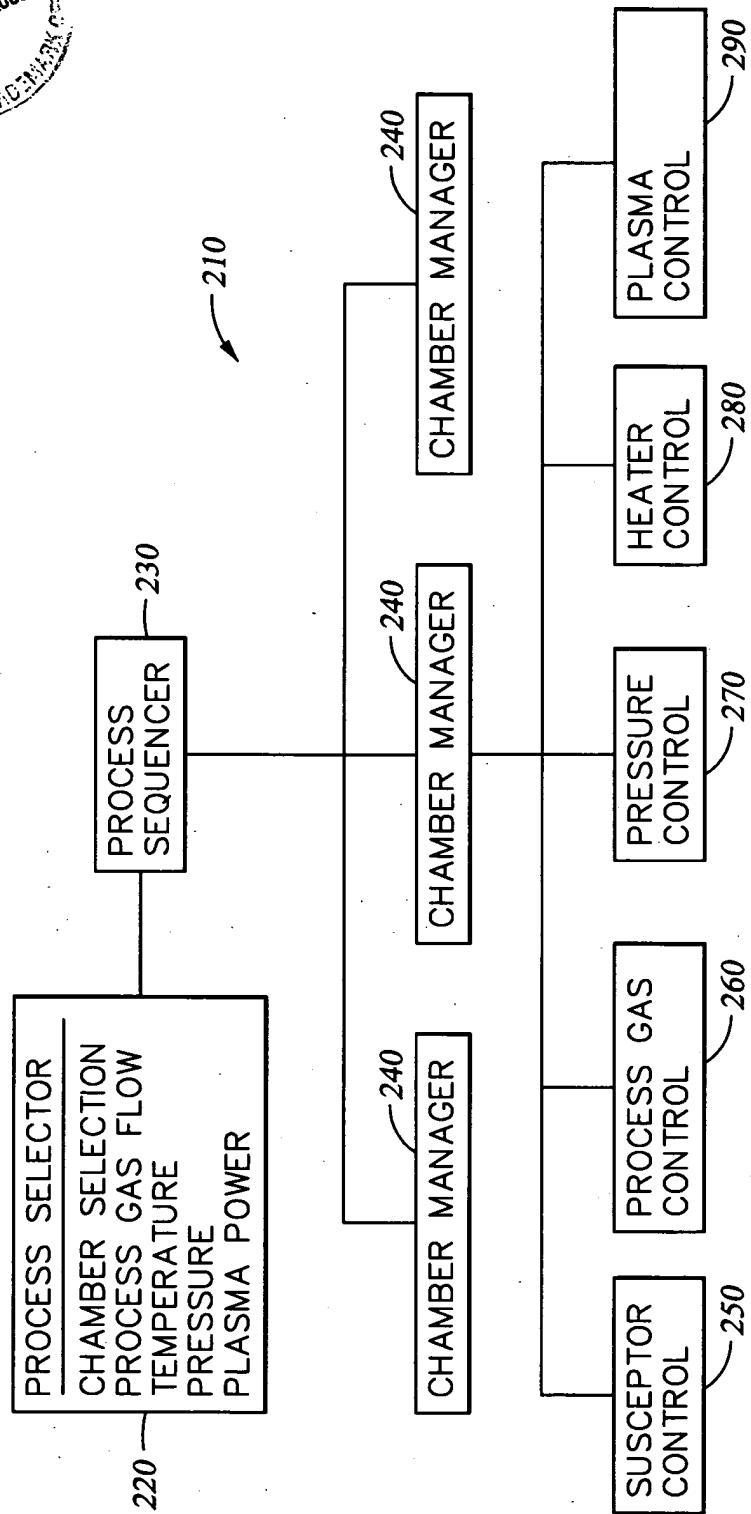


Fig. 2

ATTY DKT. NO.: U.S. SERIAL NO.:
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Fig. 3

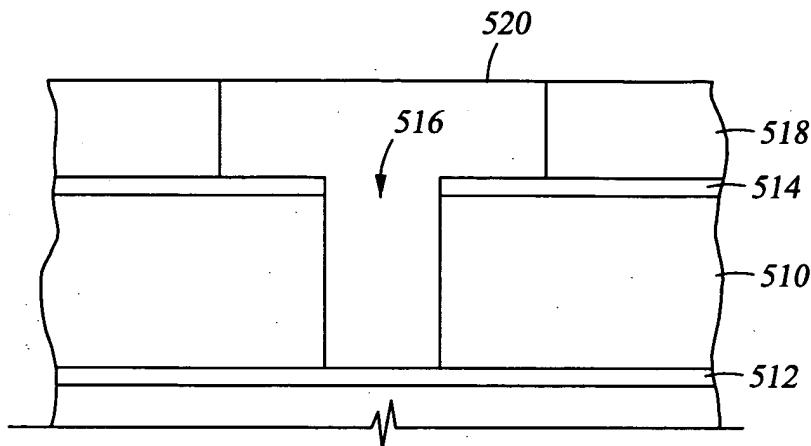


Fig. 4A

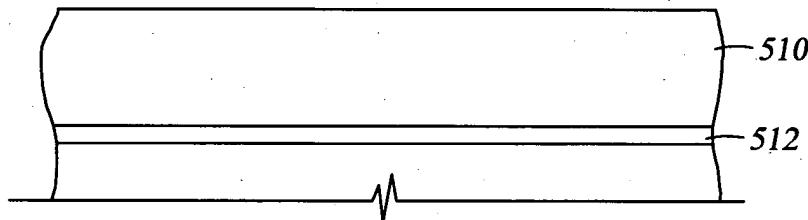


Fig. 4B

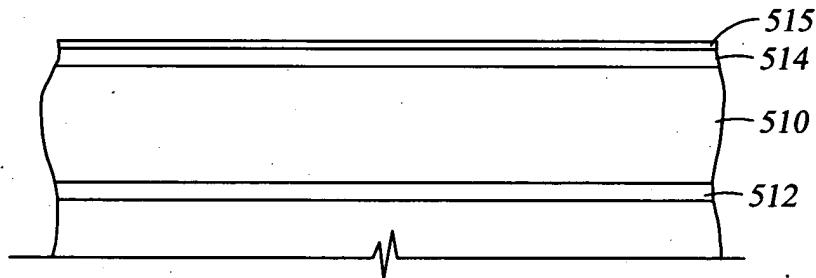
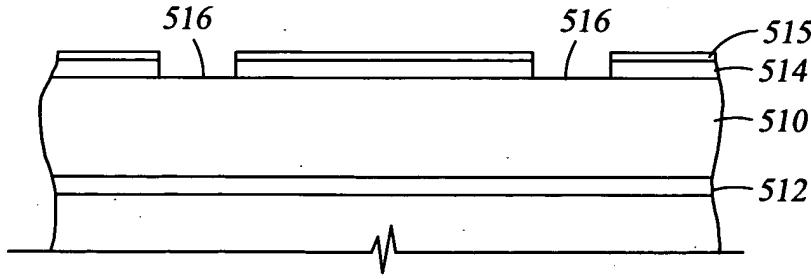


Fig. 4C



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Fig. 4D

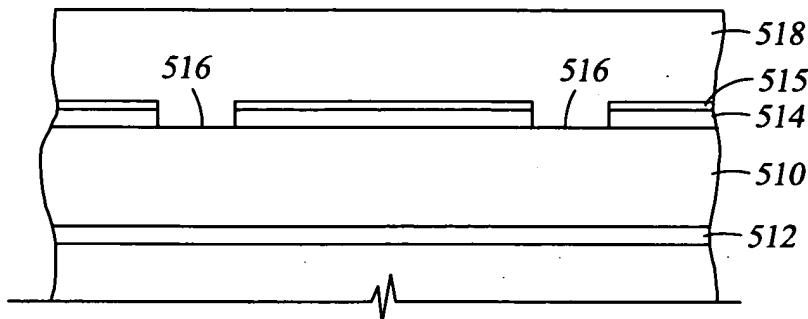


Fig. 4E

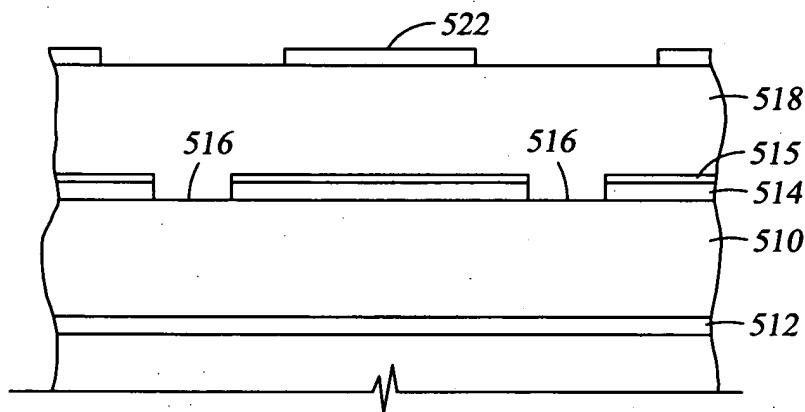
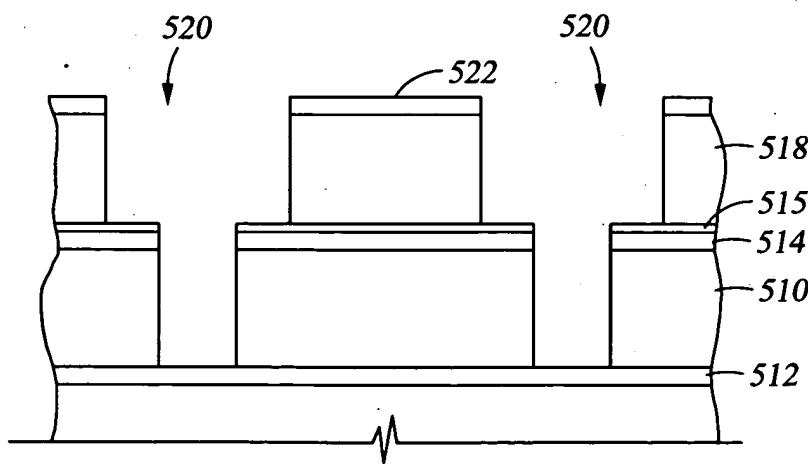


Fig. 4F



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Fig. 4G

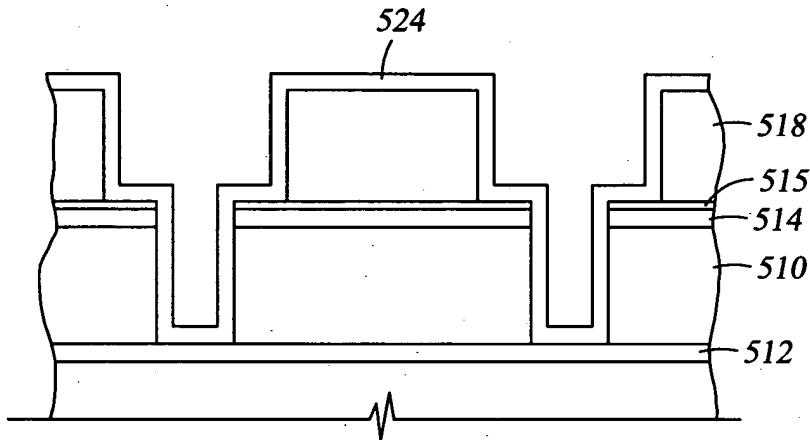


Fig. 4H

